

Serial No:

Docket No.: RD-25,905/USA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: RENATO GUIDA, ET AL
Serial No.:
Filed:
Group Art Unit:

For: **HIGH RESOLUTION ANTI-SCATTER X-RAY GRID AND LASER
FABRICATION METHOD**



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D.G.
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INFORMATION DISCLOSURE STATEMENT CONTINUING APPLICATION

Honorable Assistant Commissioner of Patents
Washington, DC 20231

SIR:

This Information Disclosure Statement is being filed under 37 C.F.R. §1.56 for a continuing application, which relies on the filing date of its parent application, such parent application being identified as:

U.S. Patent Application Serial No: 09/105,788

Examiner: K. Duda

Filed: 6/26/98

Group Art Unit: 1756

Inventor(s): Renato Guida, et al

Title: **HIGH RESOLUTION ANTI-SCATTER X-RAY GRID AND LASER
FABRICATION METHOD**

Enclosed are copies of Forms PTO-1449 listing all "prior art" cited and submitted in the parent application and Form PTO-892 listing "prior art" cited by the Examiner in the parent application. Pursuant to 37 C.F.R. §1.98(d), no actual copies of the documents listed are being furnished to the PTO with this Information Disclosure Statement.

Respectfully submitted,

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